

# ***First results on electric field distribution in irradiated epi-Si detectors***

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## *Outline*

1. Background:  $E(x)$  distribution in heavily irradiated detectors
  2. Approach for simulation of detector Double Peak response and  $E(x)$  profile reconstruction with a consideration of electric field in the “neutral” base
  3. Experimental current pulse response in epi-Si SMART detectors irradiated by 1 MeV neutrons and 26 MeV protons and  $E(x)$  profiles
  4.  $E(x)$  profiles in epi-Si detectors reconstructed from current pulse response
- Conclusions

## ***Electric field distribution in heavily irradiated Si detectors***

### **✔ Heavily irradiated detector: Double Junction (DJ) structure:**

*Z. Li, H. W. Kraner, IEEE TNS 39 (1992) 577*

### **✔ Two depleted regions and a neutral base *in-between***

*D. Menichelli, M. Bruzzi, Z. Li, V. Eremin, NIM A 426 (1999) 135*

### **✔ Two depleted regions and a base *in-between* with electric field due to potential drop over high resistivity bulk**

*E. Verbitskaya et al. NIM A 557 (2006) 528-539; “Concept of Double Peak electric field distribution in the development of radiation hard silicon detectors; pres. RESMDD’6, NIM A (in press)*

### ***Experimental verification:***

*A. Castaldini, A. Cavallini, L. Polenta, F. Nava, C. Canali, NIM A476 (2002) 550*

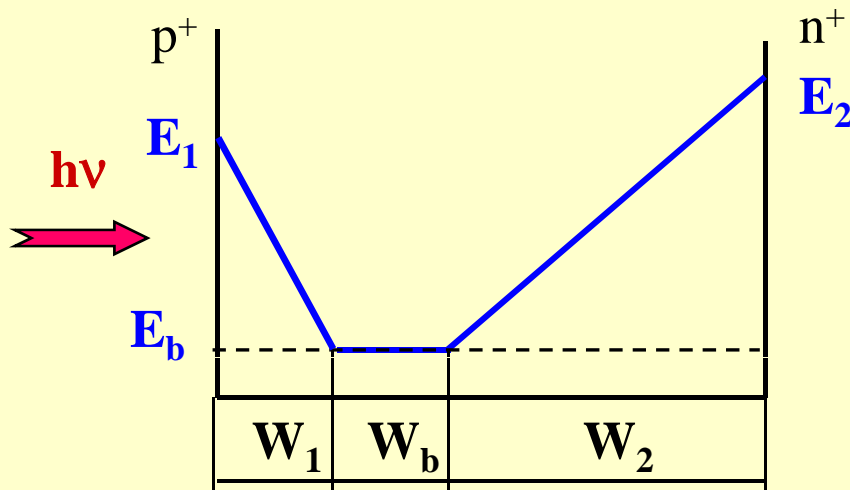
*E. Verbitskaya et al., 11 RD50 Workshop, CERN, Geneva, Nov 12-14, 2007*

## Approach for simulation of detector Double Peak response and $E(x)$ profile reconstruction with a consideration of electric field in the “neutral” base

Initiated by PTI, developed in:

- 1) *E. Verbitskaya et al. NIM A 557 (2006) 528;*
- 2) *E. Verbitskaya, Concept of Double Peak electric field distribution in the development of radiation hard silicon detectors; pres. RESMDD'6, NIM A (in press)*

- ✓ Three regions of heavily irradiated detector structure are considered
- ✓ **Reverse current flow creates potential difference and electric field in the neutral base**

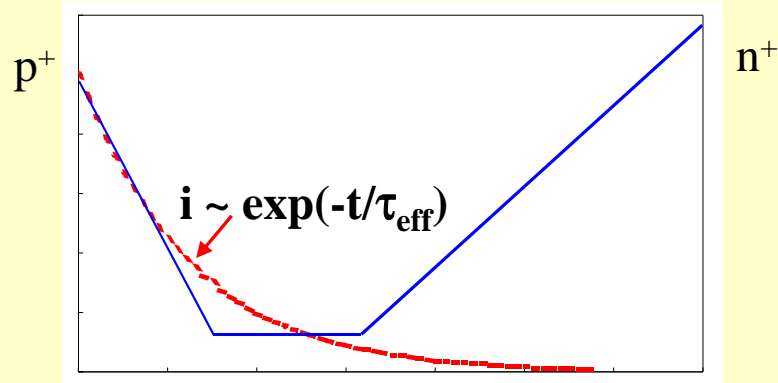


**Transient current:**

$$i(t) = \frac{Q_o \mu E}{d} e^{-t/\tau_{tr}}$$

$$\tau_{tr} = \frac{1}{\sigma v_{th} N_{tr}} \quad N_{tr} = f(F)$$

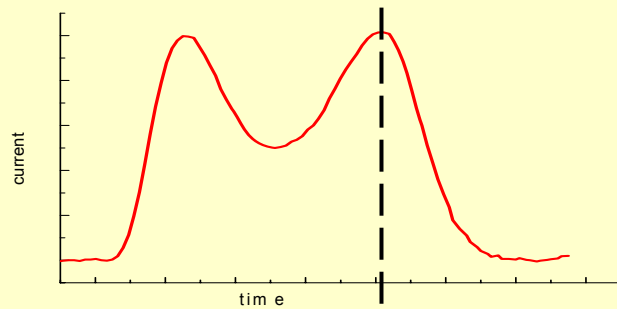
**Simulation of detector Double Peak response  
and  $E(x)$  profile reconstruction  
with a consideration of electric field in the “neutral” base**



Signal due to carrier drift in  $W_1$  is independent on the properties of  $W_b$  and  $W_2$

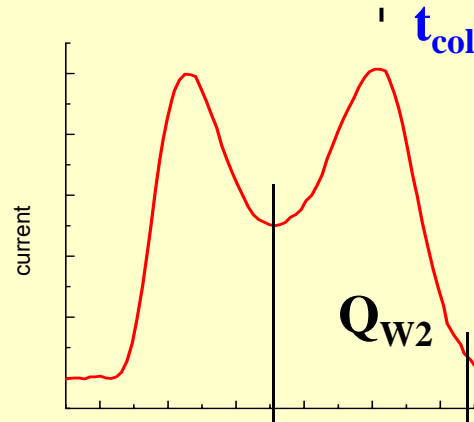
$$i = i_1 \sim \exp(-t/\tau_{tr})$$

$$\Rightarrow W_1, N_{eff1}, E_1$$



$t_{col}$ : depends on  $E_b$  and  $W_b$

$$\Rightarrow E_b, W_b$$



Charge collected inside  $W_2$

$$Q_{W2} = Q_o(d - W_1 - W_n)/d$$

$$\Rightarrow W_b, W_2, E_2, N_{eff2}$$

$$\int E dx = V$$

***New development of  $E(x)$  profile reconstruction  
with a consideration of electric field in the “neutral” base***

Special algorithm and software are developed which give direct calculation of the electric field distribution

- ◆ Current pulse response is considered as drift current

$$i(t) = en\mu E(x)$$

- ◆ Correction for carrier trapping is done

$$i(t)_{corr} = i(t) \cdot \exp(t / \tau_{tr})$$

- ◆  $\tau_{tr}$  is parameter dependent on fluence
- ◆  $\int E dx = V$  at  $x = d$

## ***Current pulse response in irradiated epi-Si SMART detectors***

**Detectors: SMART, p+ - n-epi Si - n+ wafer**

Epi-layer thickness: 150  $\mu\text{m}$

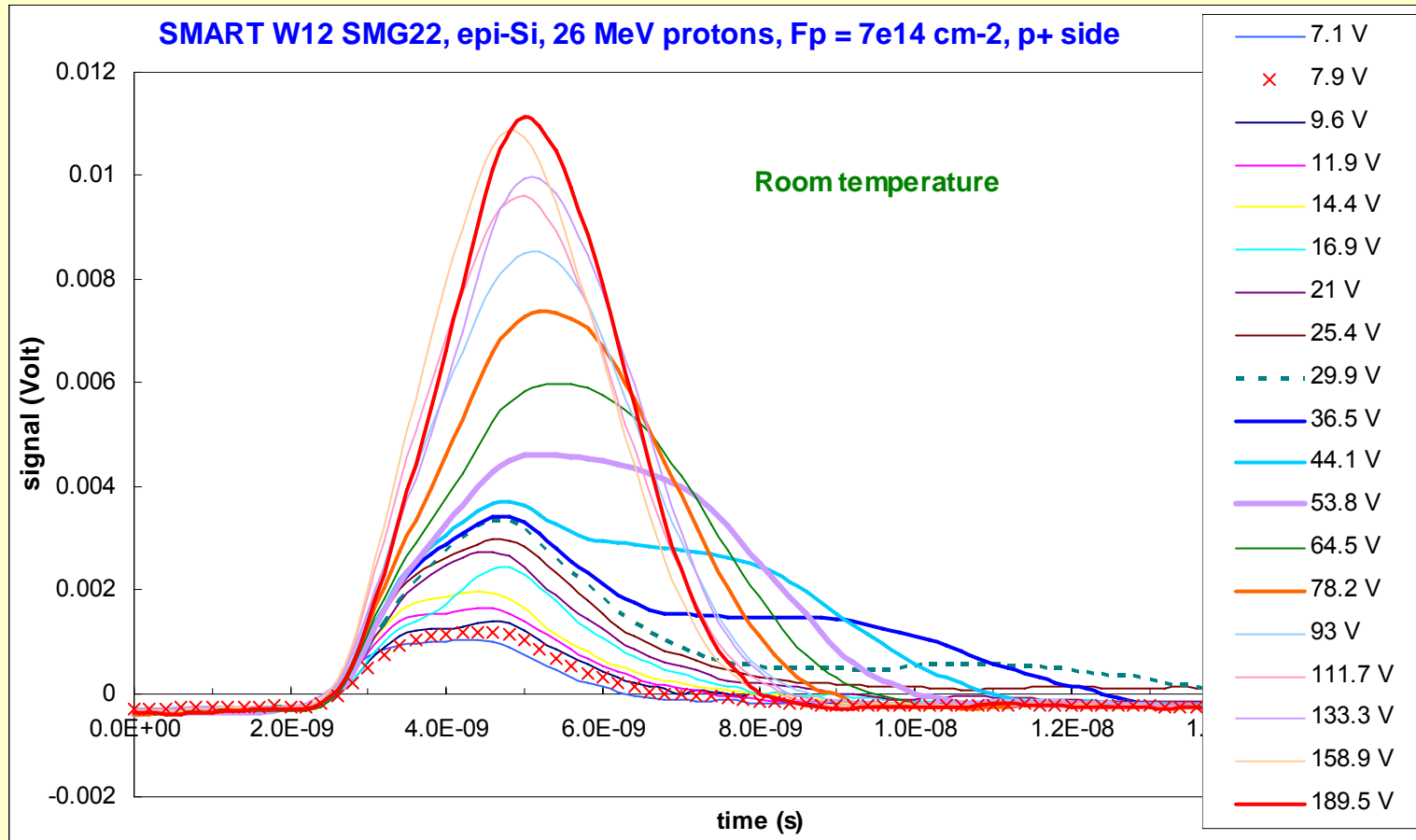
#	irradiation	equiv. fluence (cm <sup>-2</sup> )	annealing	
			T	time (min)
W12 SMG22	26 MeV protons	7.00E+14	80C	60
W13 SMG 15	1 Mev Neutrons	8.50E+14	no annealing	
W12 SMG 15	1 Mev Neutrons	8.50E+14	80C	60

**Experimental Technique: TCT setup at Ioffe Institute**

TCT setup response      0.8 ns  
Temperature range      77 – 373K  
Laser wavelength      830  $\mu\text{m}$

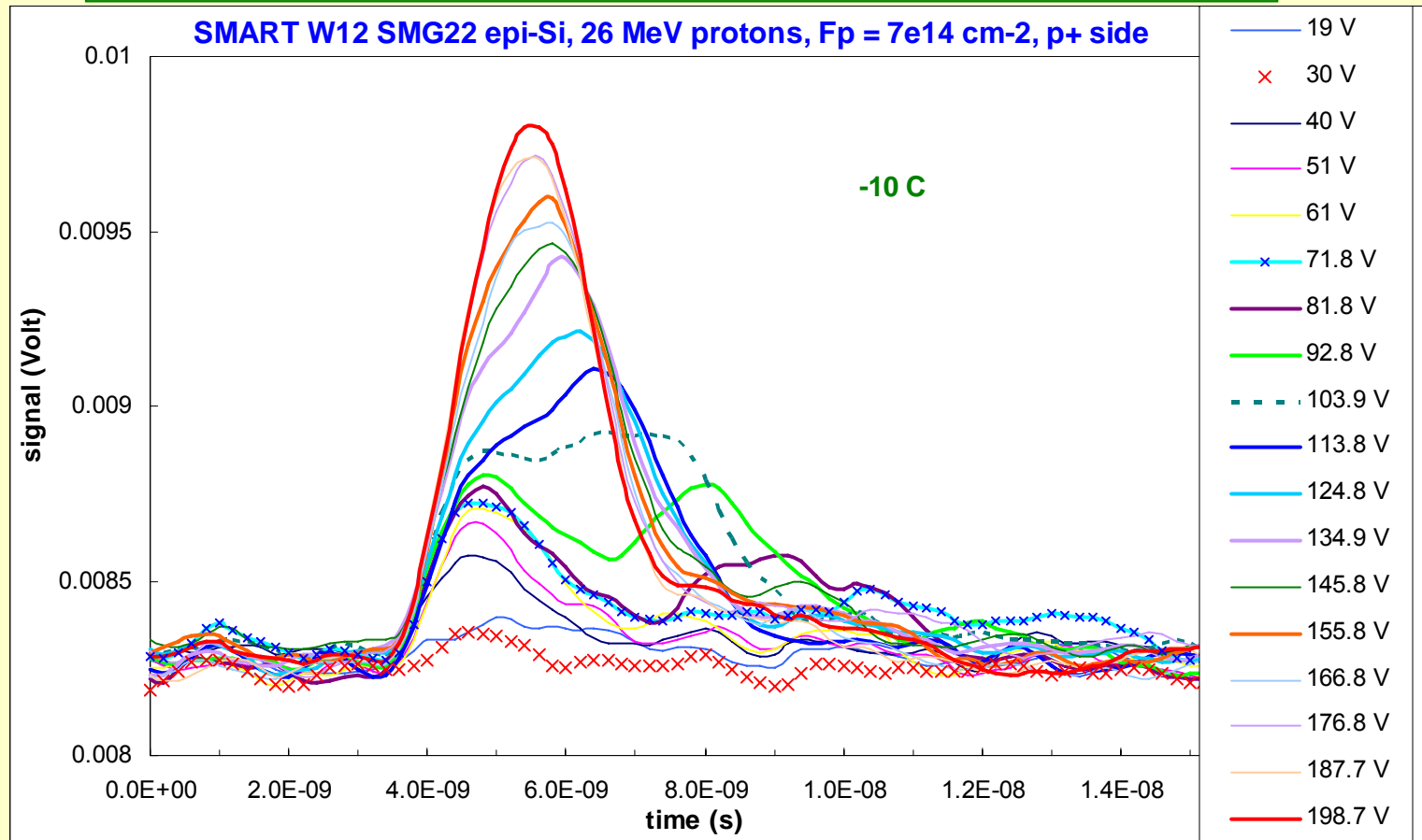
**All experiments: Laser at p+ side: electron collection**

## Current pulse response in proton irradiated epi-Si SMART detectors





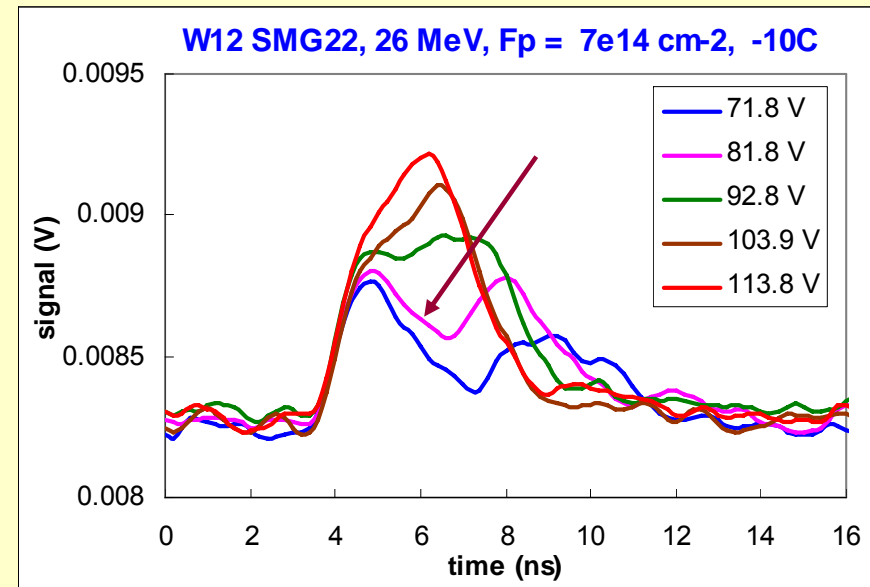
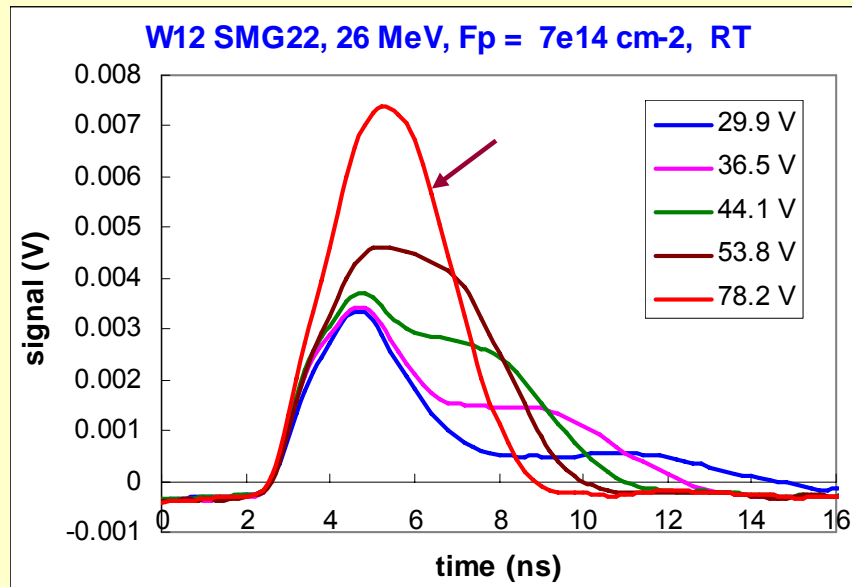
## Current pulse response in proton irradiated epi-Si SMART detectors



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## Current pulse response in proton irradiated epi-Si SMART detectors

26 MeV protons,  $F_p = 7e14 \text{ cm}^{-2}$

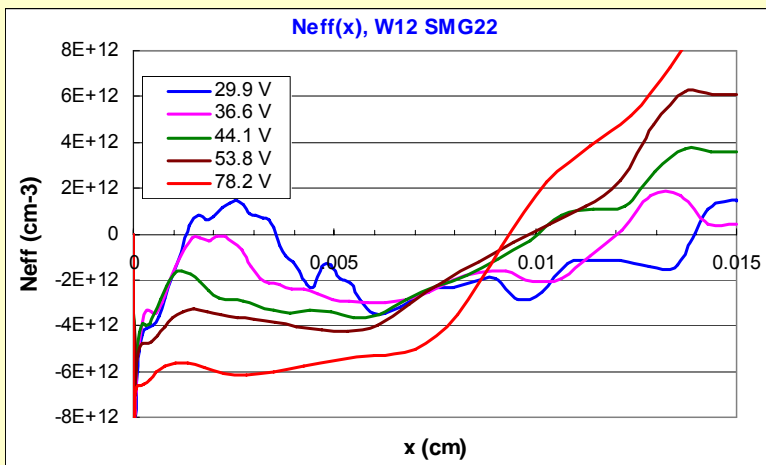
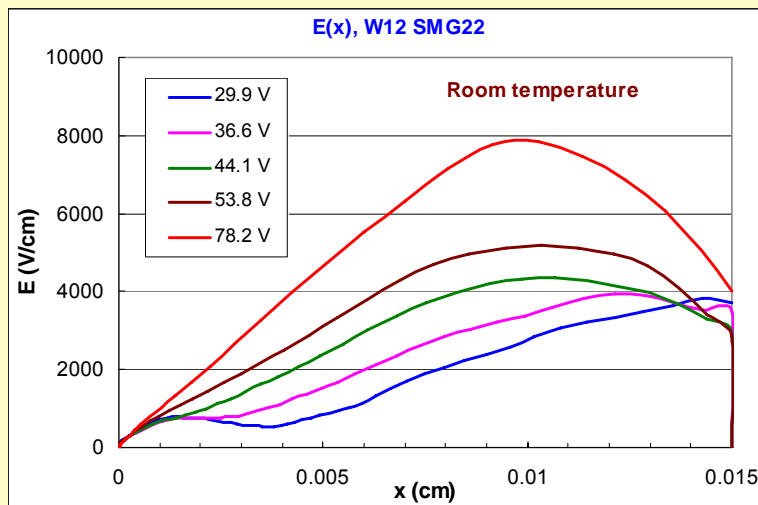


Full depletion at -10C occurs at higher V

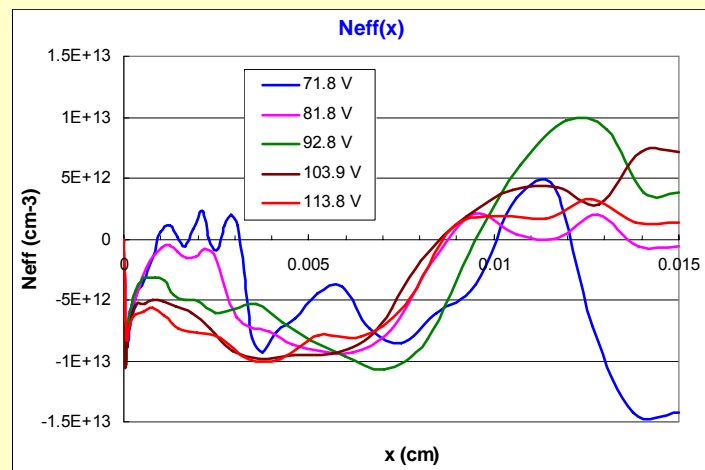
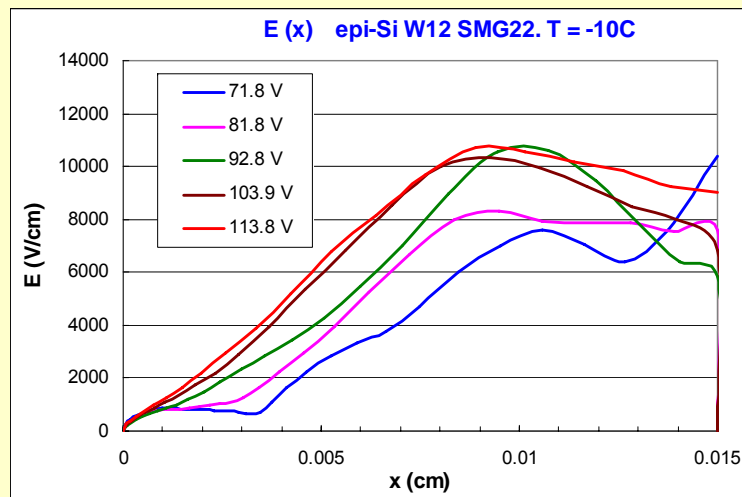
*E. Verbitskaya et al., 11 RD50 Workshop, CERN, Geneva, Nov 12-14, 2007*

# $E(x)$ and $N_{eff}(x)$ profiles in proton irradiated epi-Si detectors

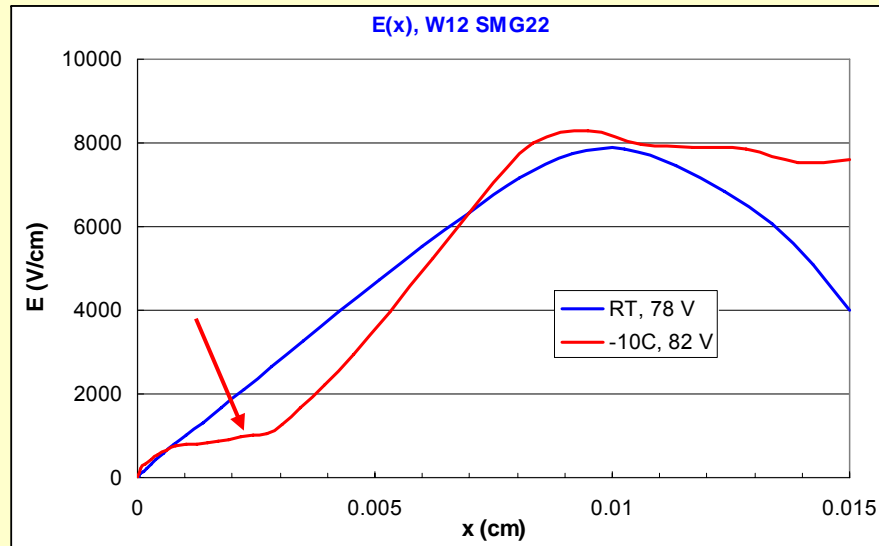
**RT**



**T = -10C**

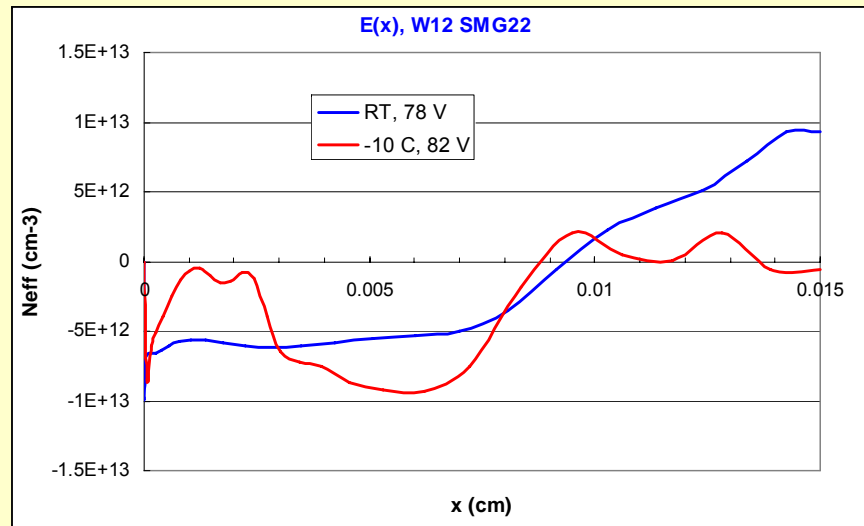


## *$E(x)$ and $N_{\text{eff}}(x)$ profiles: comparison at different temperatures*



Base region exists near the p+ contact:

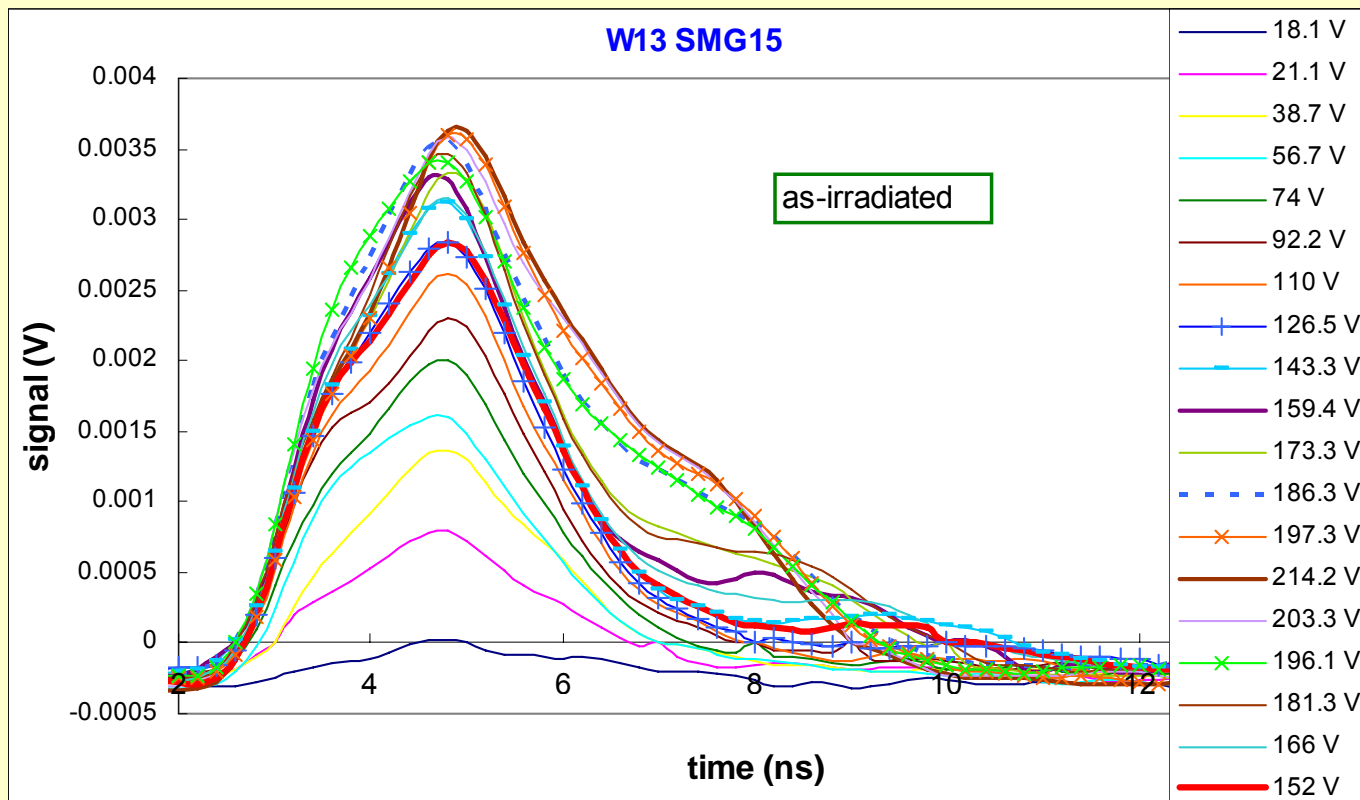
RT:  $V \leq 40$  V  
 -10C:  $V \leq 80$  V



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## Current pulse response in neutron irradiated epi-Si SMART detectors

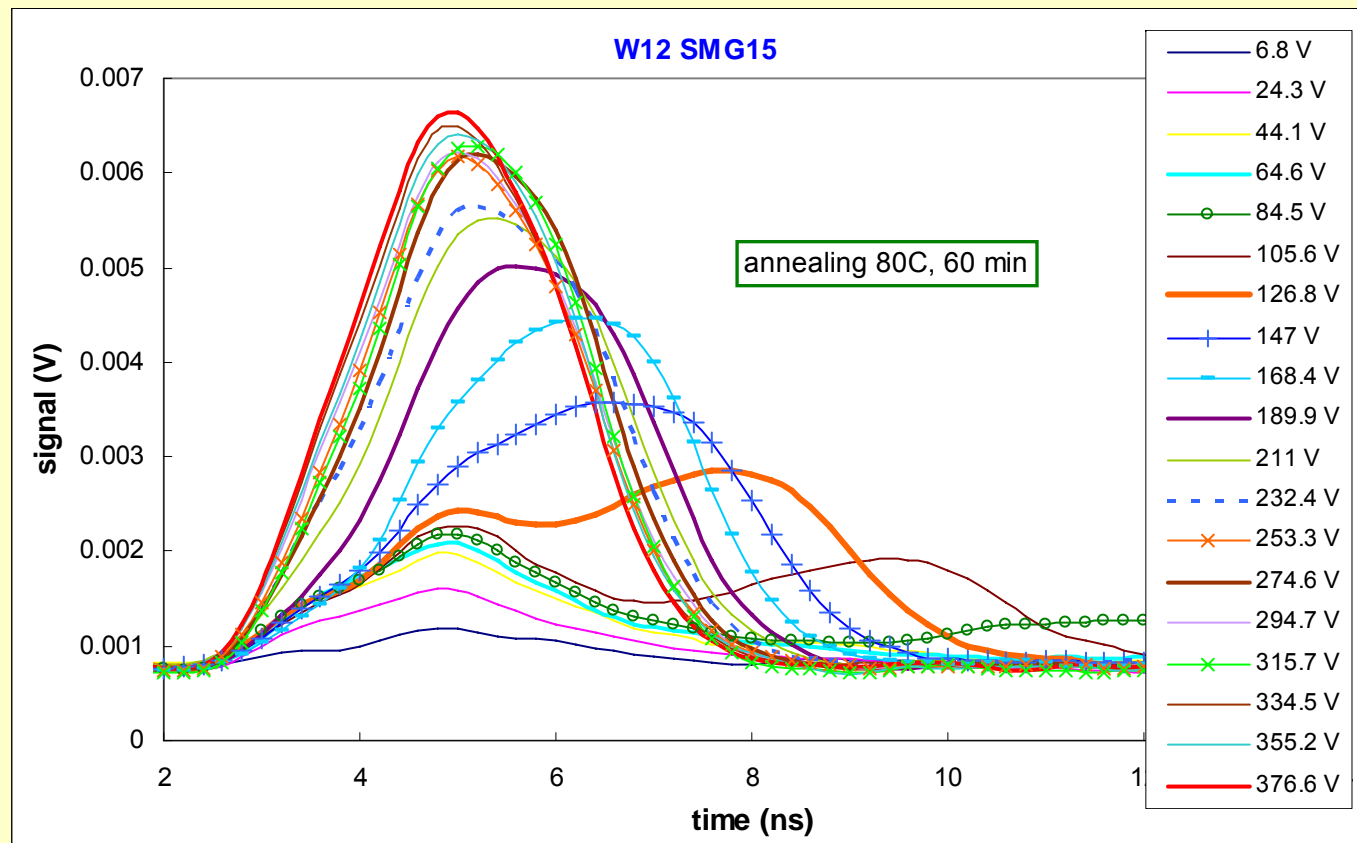
W13 SMG15,  $F_n = 8.5 \cdot 10^{14} \text{ cm}^{-2}$ , as-irradiated



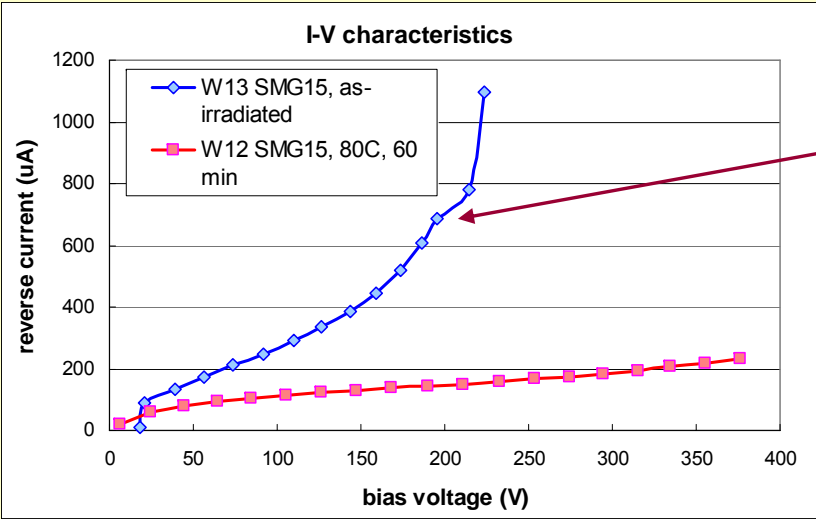
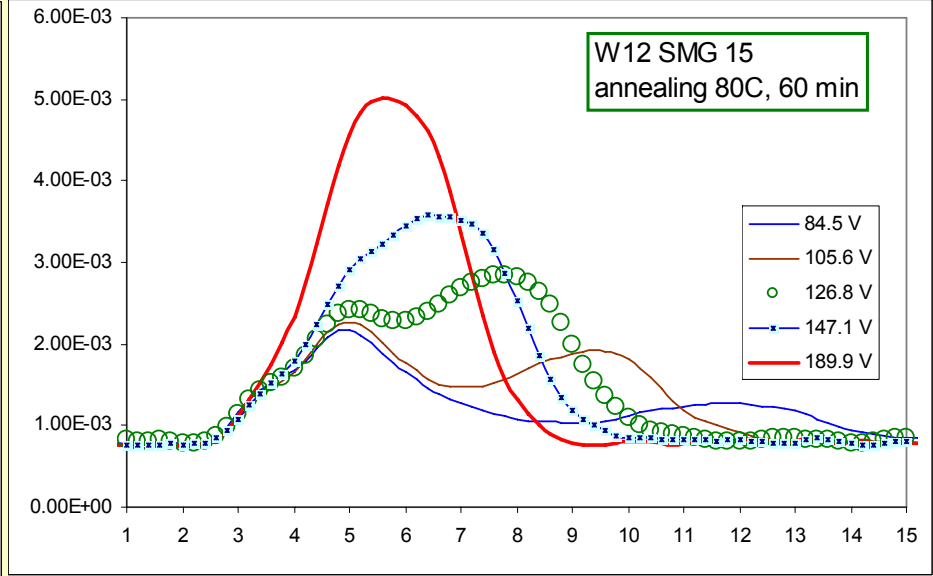
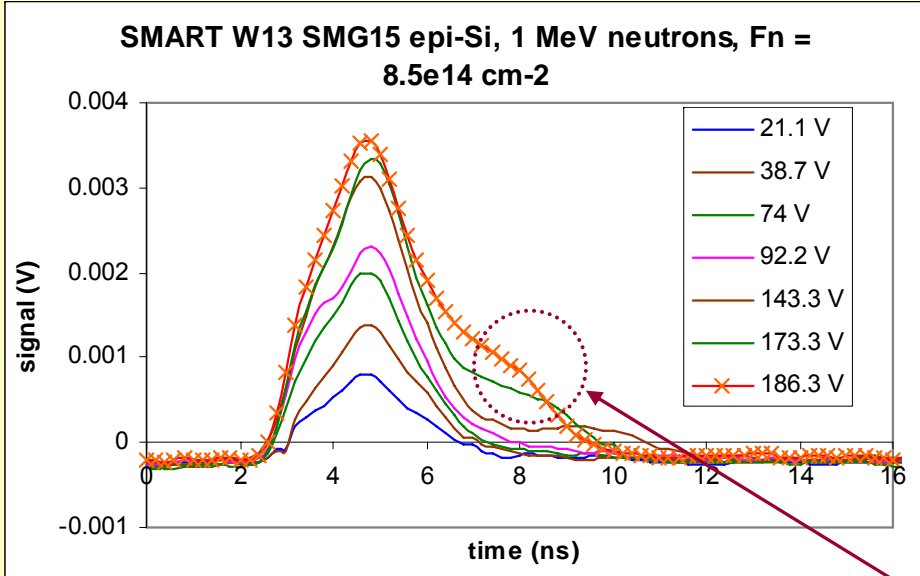
Reverse current is significant at  $V > 200 \text{ V}$

# Current pulse response in neutron irradiated epi-Si SMART detectors

W12 SMG15,  $F_n = 8.5 \cdot 10^{14} \text{ cm}^{-2}$ , annealed 80C, 60 min



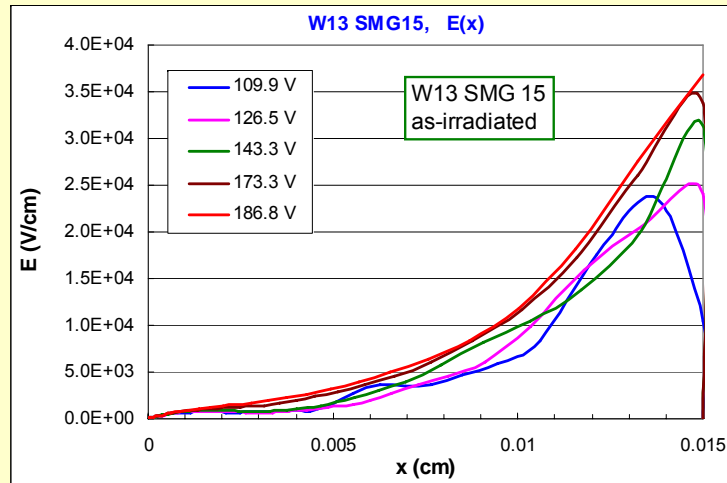
# Current pulse response in neutron irradiated epi-Si detectors



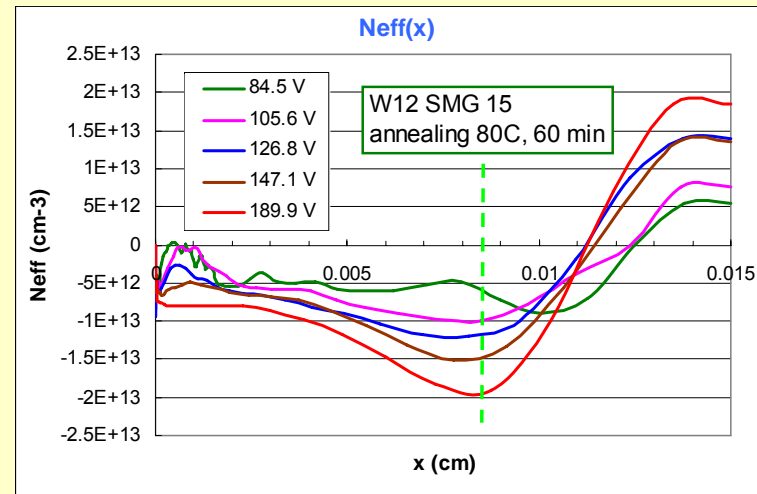
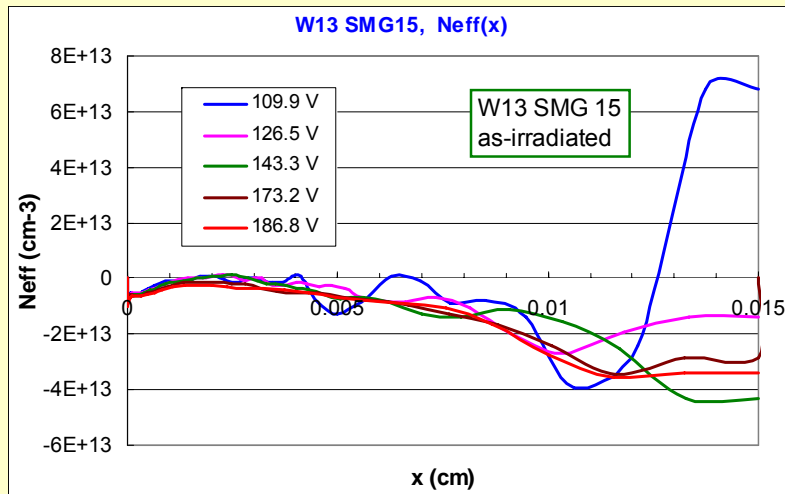
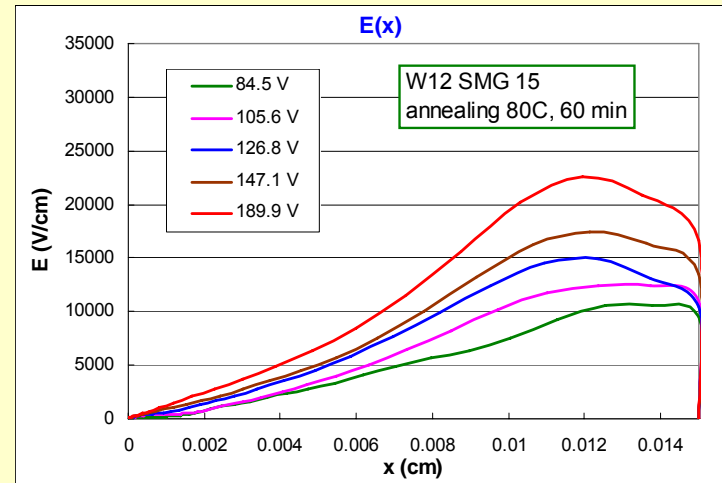
- ◆ Annealing results in significant reduction of current.
- ◆ Increase of electric field near the **interface wafer-epi-layer** due to carrier trapping from enhanced current at higher V?

# $E(x)$ and $N_{eff}(x)$ profiles in neutron irradiated epi-Si detectors

W13 SMG15, as-irradiated



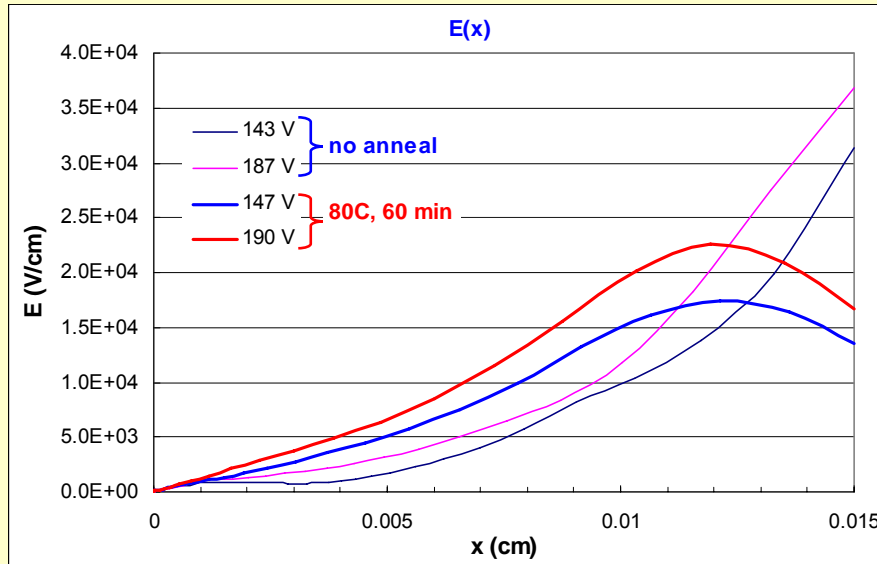
W12 SMG15, anneal 80C, 60 min



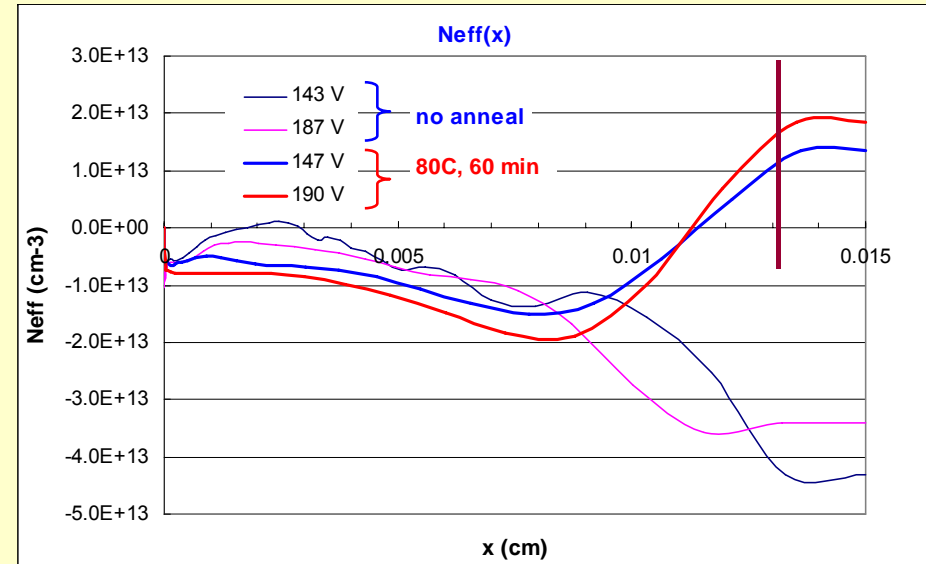


## *$E(x)$ and $N_{eff}(x)$ profiles: comparison of as-irradiated and annealed detectors*

$E(x)$



$N_{eff}(x)$



- ◆  $E$  at n+ contact is higher in as-irradiated detector
- ◆ Low field base region near p+ contact exists in both detectors, annealing doesn't eliminate it

## *Trapping time constants*

Proton irradiated,  $7 \cdot 10^{14} \text{ cm}^{-2}$ : 1.6-1.8 ns

Neutron irradiated,  $8.5 \cdot 10^{14} \text{ cm}^{-2}$ :

1.1 ns – as-irradiated

1.4 ns - annealed

## Conclusions

- ✓ *SCSI occurs in epi-Si detectors irradiated by 26 MeV protons and 1 MeV neutrons ( $F = (7-8) \cdot 10^{14} \text{ cm}^{-2}$ ).*
- ✓ DP response in epi-Si irradiated detectors is related with base region rather than with DP  $E(x)$ . Electric field in the base regions arises from current flow and potential drop over the base.
- ✓ Base region with rather high  $E$  ( $\sim$ few kV/cm) extends near the surface of the epi-layer.
- ✓ *As-irradiated detector – enhanced current and increase of electric field related to trapping at the  $n^+$  contact? – needs additional study.*
- ✓ New method of  $E(x)$  reconstruction in irradiated Si detectors is universal and is related to minimal number of parameters.

# *Acknowledgements*

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*Thank you for your attention!*